

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of

Applicant : Gurtej S. Sandhu
Serial No. : 10/765,314
Filed : January 27, 2004
Title : ATOMIC LAYER DEPOSITION WITH POINT OF USE GENERATED
REACTIVE GAS SPECIES
Docket : MIO 0092 NA
Examiner : Smith, Francis P.
Art Unit : 4151
Confirm. No. : 9407

EFS WEB ELECTRONIC SUBMISSION
May 2, 2008

MAIL STOP AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

AMENDMENT

The paper is being filed in response to the Office Action mailed February 4, 2008.

Reconsideration of the present application is respectfully requested in light of the amendments below, which include, in order of appearance, beginning on separate sheets:

- Amendments to the Claims; and
- Remarks.